PATENT APPLICATION



In re application of:

D. KOMADA

Serial No.: 10/040,378

Filed: January 9, 2002

Group Art Unit: 1765

Examiner: Lan Vinh

Atty. Dck. No. 107317-00040

MANUFACTURE METHOD FOR SEMICONDUCTOR DEVICE HAVING

SILICON-CONTAINING INSULATING FILM

AMENDMENT UNDER 37 CFR §1.111

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Date: September 2, 2003

Sir:

For:

In reply to the outstanding Office Action dated May 7, 2003, the period for response having been extended one month from August 7, 2003 to September 7, 2003, with the filing of the attached Petition for Extension of Time, please amend the application as shown on the following pages: